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RESPONSE UNDER 37 CFR §1.116  
EXPEDITED PROCEDURE  
TECHNOLOGY CENTER ART UNIT 2829

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Akira SHIMOKOHBE et al.

Group Art Unit: 2829

Application No.: 09/556,795

Examiner: Asok K. Sarkar

Filed: April 25, 2000

Docket No.: 106096

For: A THIN FILM-STRUCTURE AND A METHOD FOR PRODUCING THE SAME

AMENDMENT AFTER FINAL REJECTION UNDER 37 C.F.R. §1.116

Director of the U.S. Patent and Trademark Office  
Washington, D.C. 20231

Sir:

In reply to the Office Action mailed March 22, 2002, please amend the above-identified application as follows:

IN THE CLAIMS:

Please replace claim 3 as follows:

3. (Four Times Amended) A method for producing a thin film-structure comprising the steps of:

forming on a substrate a thin film made of an amorphous material film exhibiting a viscous flow within a range of  $10^8 - 10^{13}$  Pa·S when heated at a temperature within a supercooled liquid phase region;

heating the thin film to a temperature within the supercooled liquid phase region so that the thin film has a viscous flow between  $10^8 - 10^{13}$  Pa·S;

deforming the thin film to a given shape without the use of an external force;

and

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